

Editorial

This issue marks the 20th anniversary of the founding of the Journal of Thermal Analysis. *J. Thermal Anal.* (this abbreviation is often used) originated in 1969 under the guidance of Professor László Erdey.

As time went on, significant developments occurred in thermal analysis and our journal grew to keep pace with these developments. This may be illustrated by reference to merely one datum, the size of a volume: 496 pages in 1969, and 2,800 pages 20 years later.

We would like to take this opportunity to say thank you all our colleagues working on this periodical, but especially to the Regional Editors, who have worked with admirable patience in collaboration with authors and referees in order to improve the quality of the papers published. Special thanks must also be paid to the distinguished members of the Editorial Board, whose help towards the maintenance of the high scientific standard of the periodical has been invaluable.

We also wish to express our thanks to all those authors who have contributed to our success by sending us their papers, and likewise to our readers whose interest is devoted to the developments in thermal analysis.

Finally, we must mention the excellent co-operation between Akadémiai Kiadó and Wiley and Sons Ltd., which ensures a truly international character with contributors and readers worldwide.

To be present at the birth of a scientific journal and to direct its progress throughout 20 years under such pleasant circumstances is a very rewarding experiment.

The Editors